



Radiation tolerance of thin (50 & 35 μm) LGAD sensors...

...and epilogue (maybe) on I-LGAD timing

14th Workshop on Advanced Silicon Radiation Detectors

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IMB-CNM (CSIC)

Developed inside the RD50 collaboration & AIDA -2020 WP7 on Advanced Hybrid Detectors.



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AIDA 2020



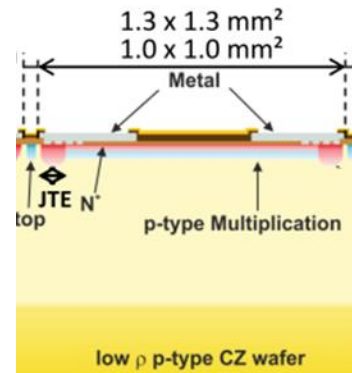
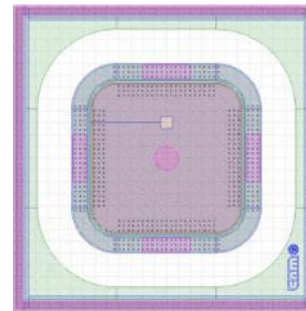
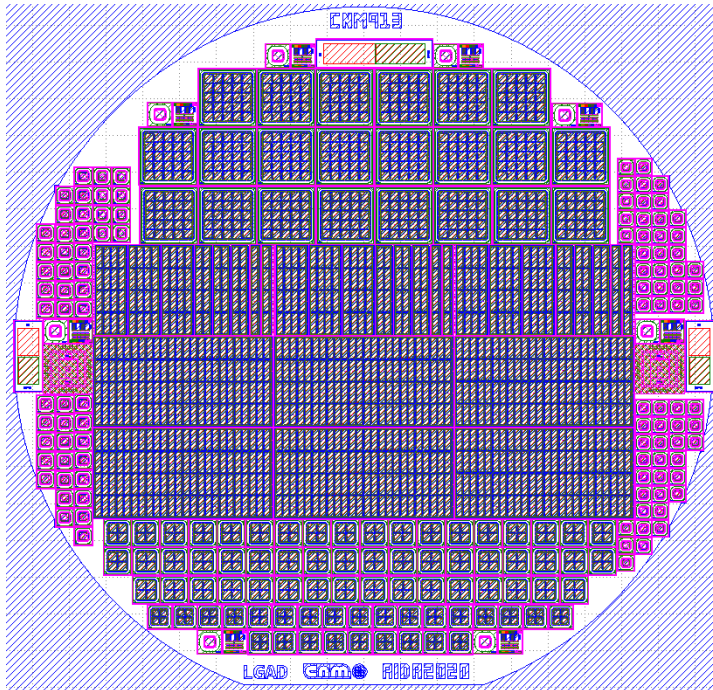
Outline



- Radiation tolerance of thin LGADs
 - _ Motivation & sample description
 - _ Electrical characterization: IV & CV
 - _ Charge collection vs fluence.
 - _ On the radiation damage mechanism(s)
 - _ Slewing rate vs fluence.
- Detailed timing study of Inverse-Low Gain Avalanche Detectors (ILGAD)
 - _ Technology description.
 - _ Performance of proof-of-concept prototype

Motivation , Samples & Irradiation points

- Compare the radiation tolerance (protons) of LGAD with **two different active thickness: 50 and 35 μm** .
- Samples form CNM Run#11748 (AIDA-2020 WP7)

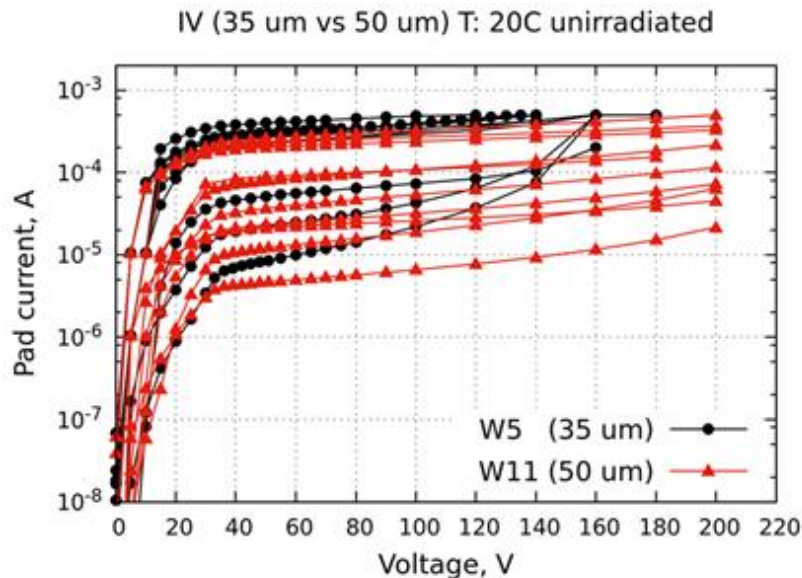


Total area of $2.6 \times 2.6 \text{ mm}^2$
 Active area of $1.3 \times 1.3 \text{ mm}^2$
 Intermediate gain

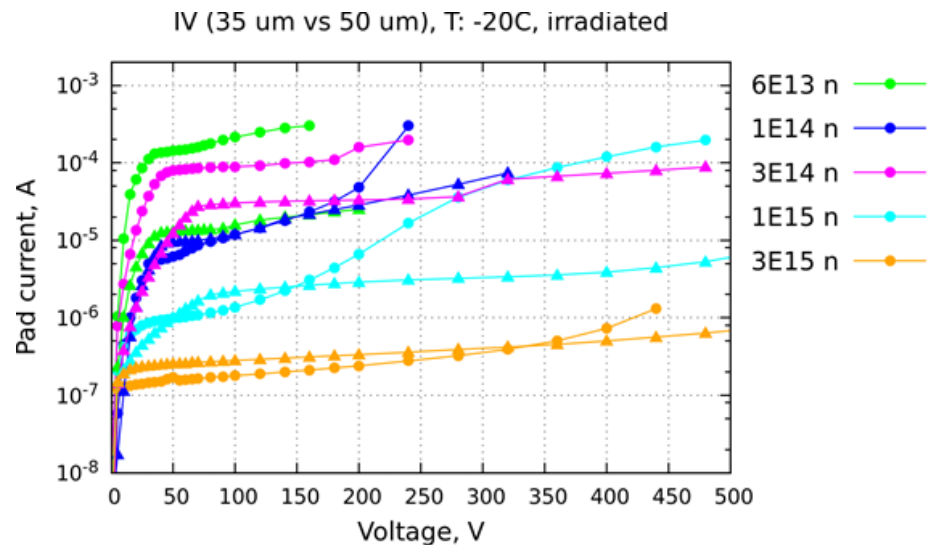
- Irradiated at CERN PS with 24 GeV protons at **5 different fluences**.
 - $6 \times 10^{13} \text{ n}_{\text{eq}}/\text{cm}^2$
 - $1 \times 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2$
 - $3 \times 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2$
 - $1 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$
 - $3 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$

Electrical Characterization: IV Curves

- Large reverse current (unexpected).
- The reverse current is suppressed by irradiation.
- Originated (most likely) at the at diode periphery (JTE structure).



BEFORE IRRADIATION

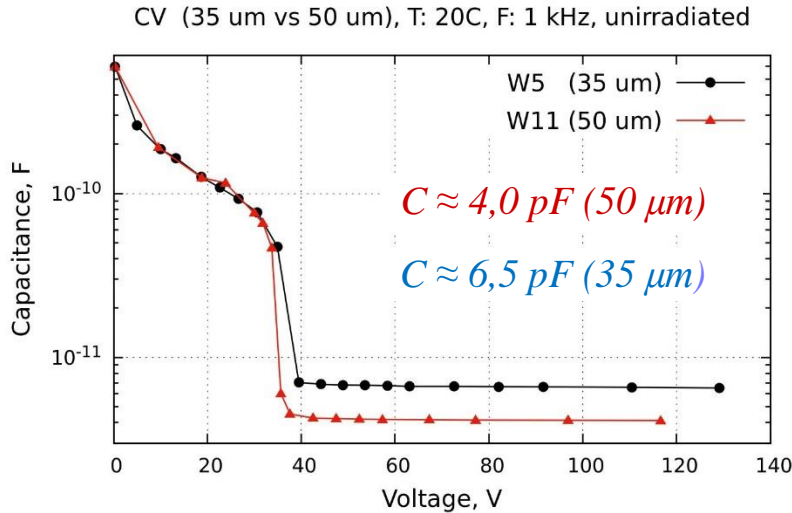


AFTER IRRADIATION

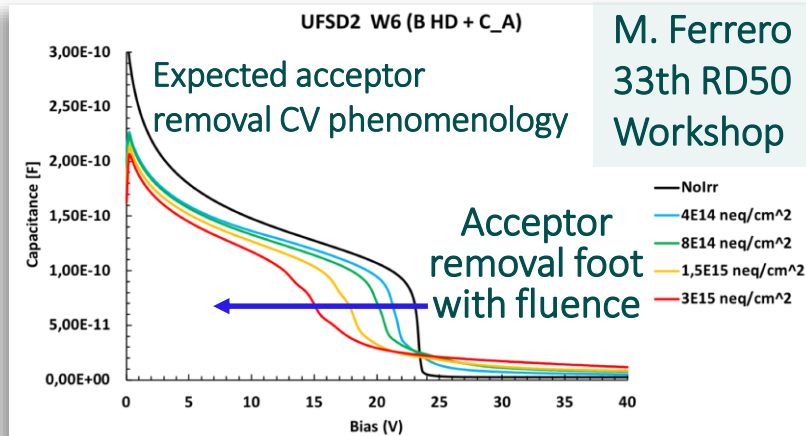
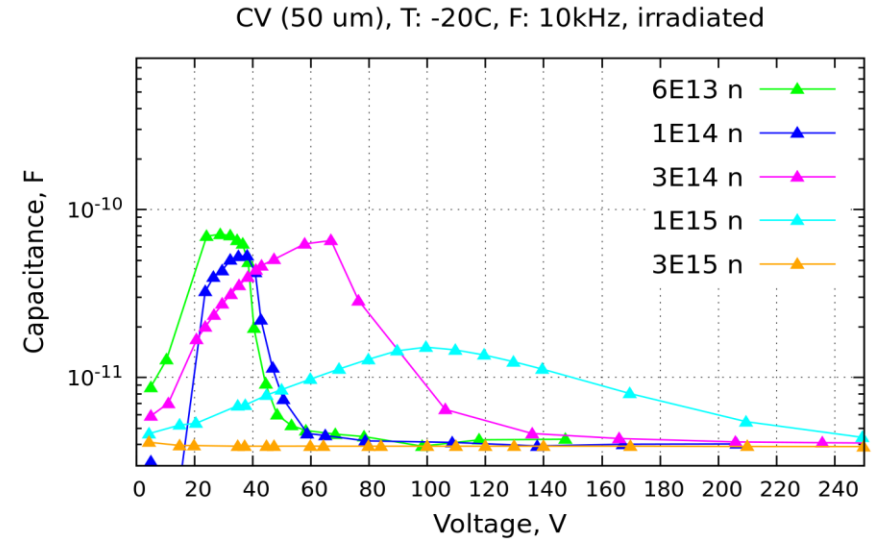
Electrical characterization: CV curves



BEFORE IRRADIATION



AFTER IRRADIATION

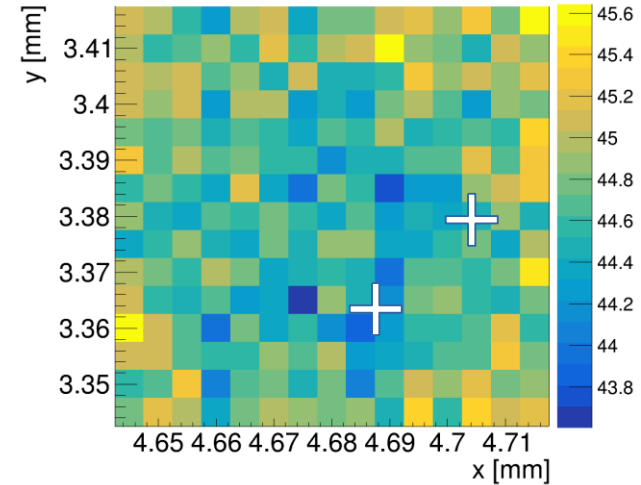


CV characteristics does not follow simple acceptor removal model after irradiation (to be discussed)

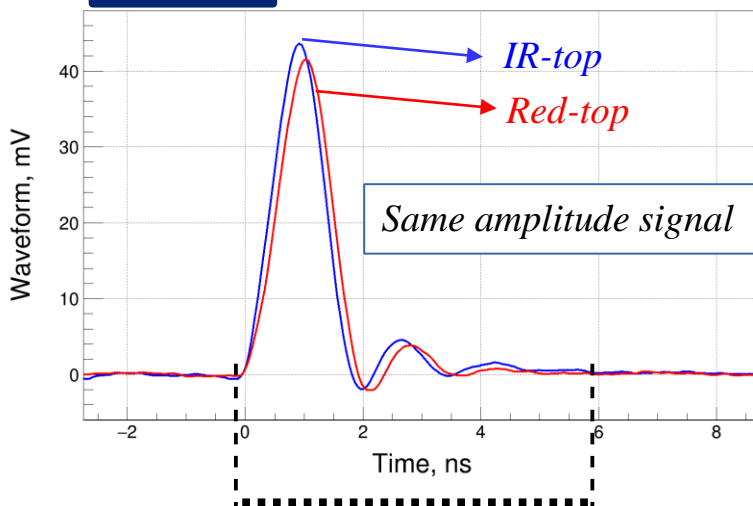
TCT Characterization: Charge Collection Uniformity

- ◆ IR laser and red laser
- ◆ Top illumination
- ◆ Same laser intensity in both cases
- ◆ Temperature: -20 C
- ◆ Amplifier: CIVIDEC C2, 2 GHz, 40 dB
- ◆ Oscilloscope: Agilent DSO 9254, 2.5 GHz, 20 GSa/s
- ◆ Averaging of 256.

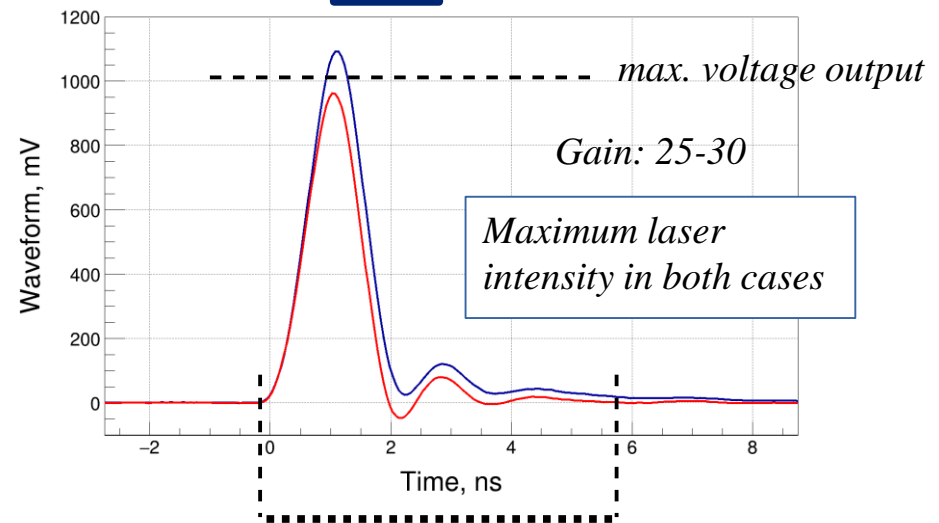
2D amplitude map, mV



PIN diode W11 (50 μ m), Voltage: 100 V



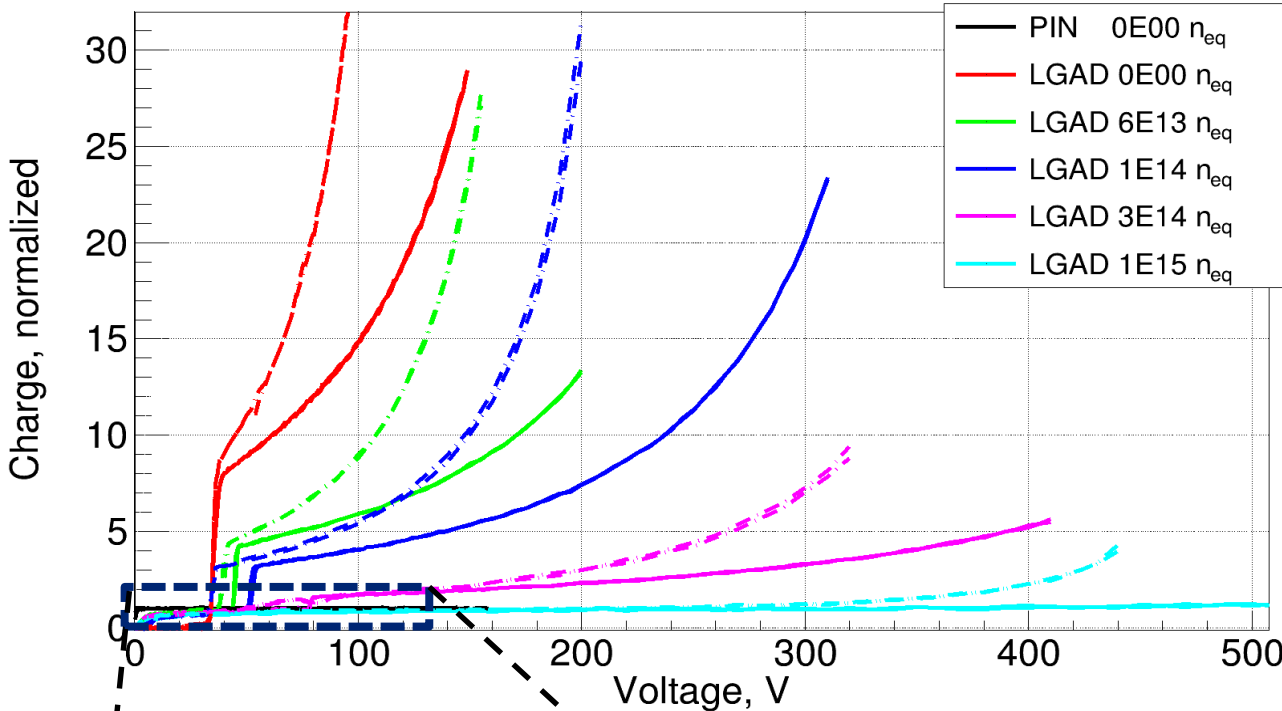
Unirradiated **LGAD** W11 (50 μ m), Voltage: 150 V



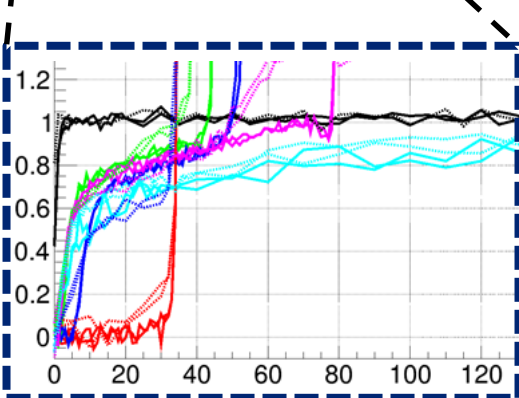
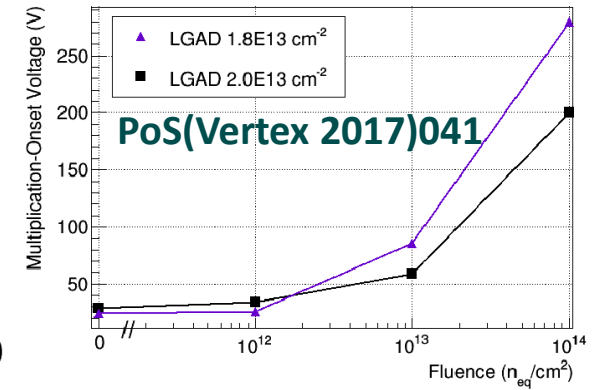
TCT Characterization: Charge vs. Bias Voltage



TCT IR-top, 35 μm (dashed lines) vs 50 μm (continuous lines), -20°C



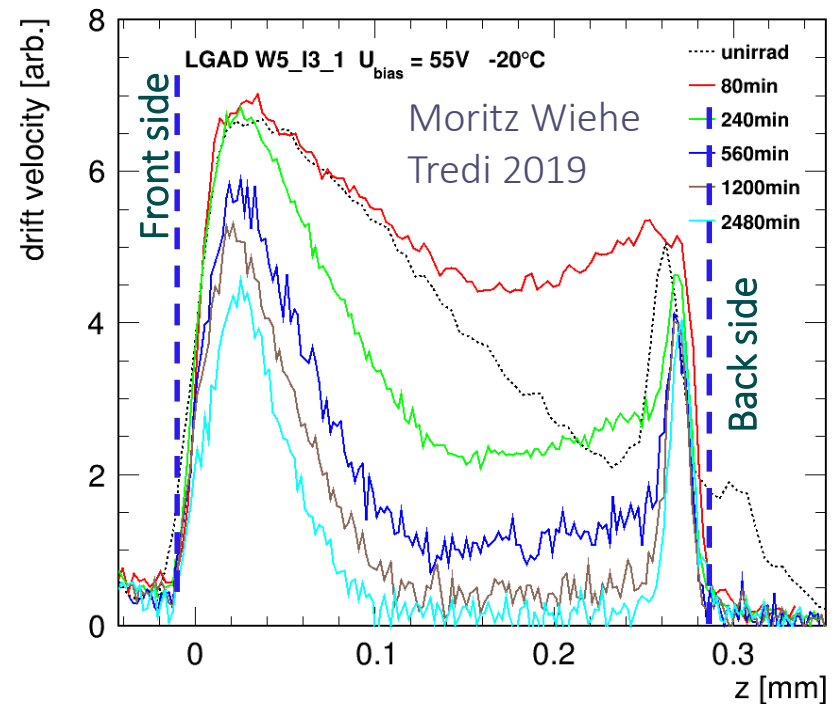
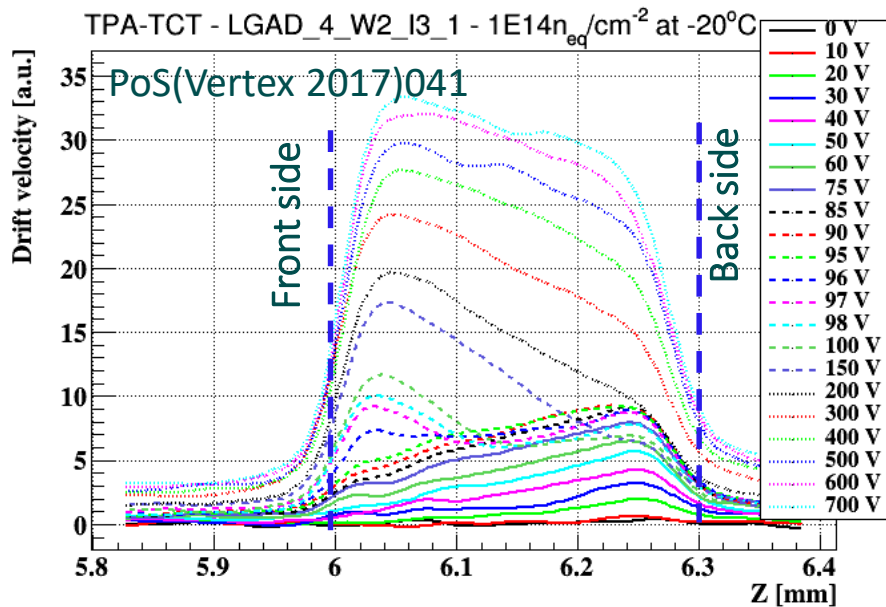
Positive shift of gain offset observed in [S. Otero et al., PoS(Vertex 2017)041] on 300 μm thick sensors.



| Fluence ($n_{\text{eq}}/\text{cm}^2$) | On-set Voltage (Volts) | CV Voltage@maximum |
|---|------------------------|--------------------|
| 0 | 30-35 | 35(CV foot) |
| 6e13 | 40-45 | 35 |
| 1e14 | 45-50 | 40 |
| 3e14 | 75-80 | 70 |

TCT Characterization: Charge vs. Bias Voltage (2)

- Positive shift of charge collection on-set observed previously in 300mm thick pad diodes with low reverse currents (few hundrend of nA on irradi).
- Caused by the Bulk Space Charge Inversion (BSCI) (trapped carriers)
- Double peaked E-field (velocity) with TPA-TCT and E-TCT profiles demonstrated BSCI.

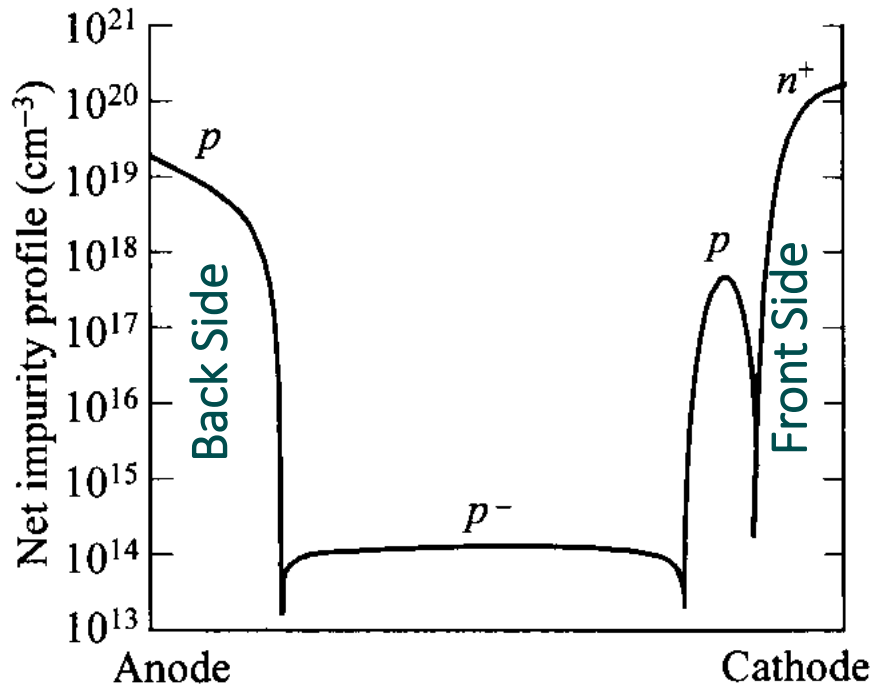


Does the BSCI induce the shift on the gain on-set?

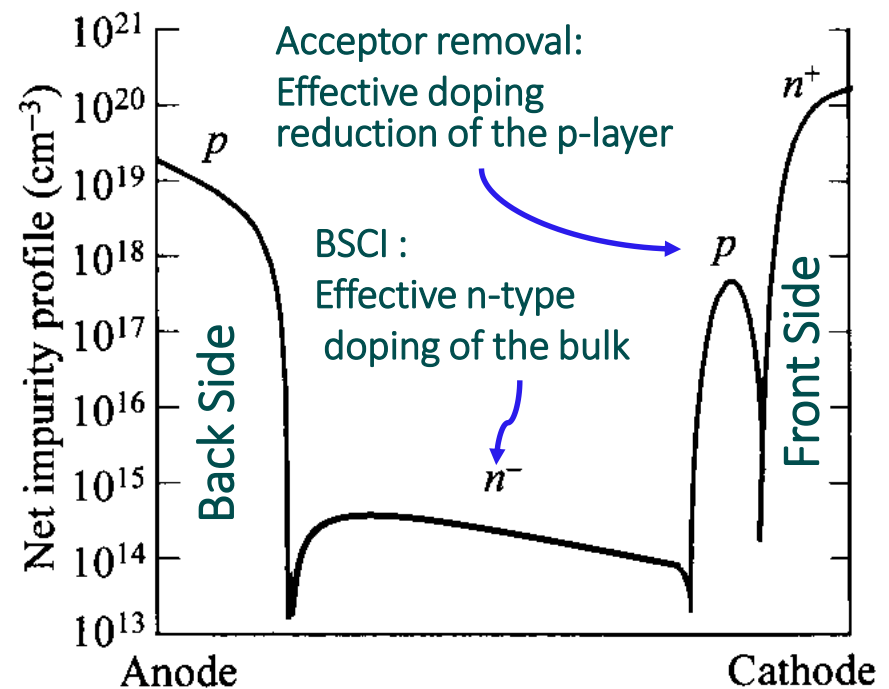
CV characteristic (revisited) - I

- Due to the BSCI of the p bulk, the LGAD becomes effectively a **Shockley four-layer diode** (aka Thyristor with floating gate).
- Can we explain the CV characteristic based on a Shockley four-layer diode?

Before irradiation,



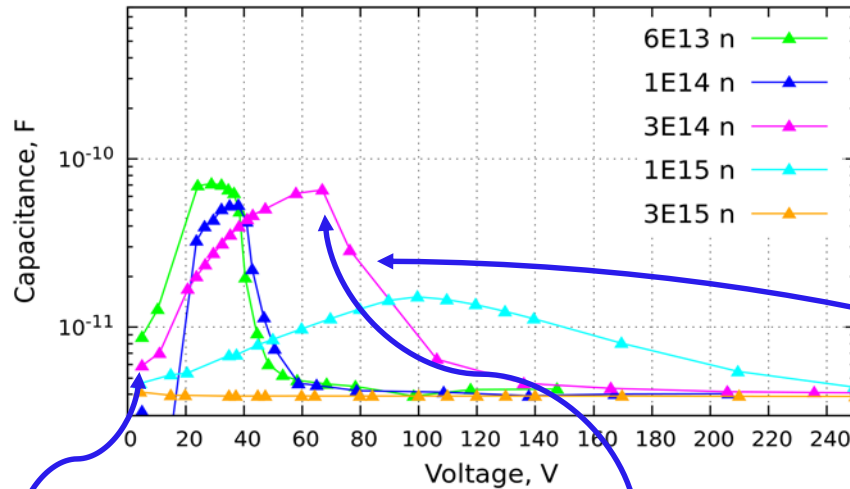
After irradiation,



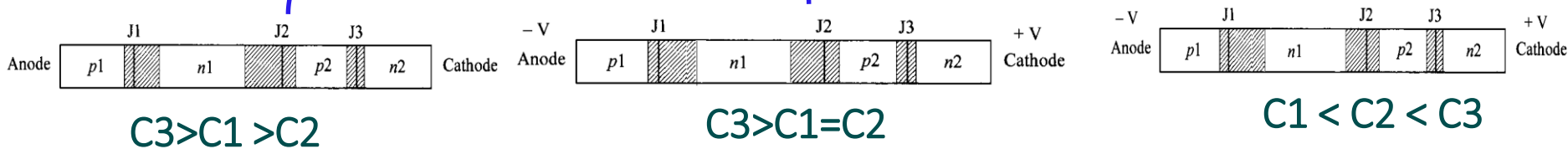
CV characteristic (revisited) - II

- The multijunction total capacitance is small than the smallest single junction capacitance.
- No biased:
 - J1 & J3 built-in field with same direction, J2 oposite
- Under bias(VR):
 - J1 & J3 reverse biased but **J2 is forward biased**.
 - J2 capacitance increases with VR while J1 & J3 decrease with VR.
 - Eventually J2 is not longer the smallest capacitance, J1 dominates (back side depletion and then J3 depletion)

CV (50 um), T: -20C, F: 10kHz, irradiated

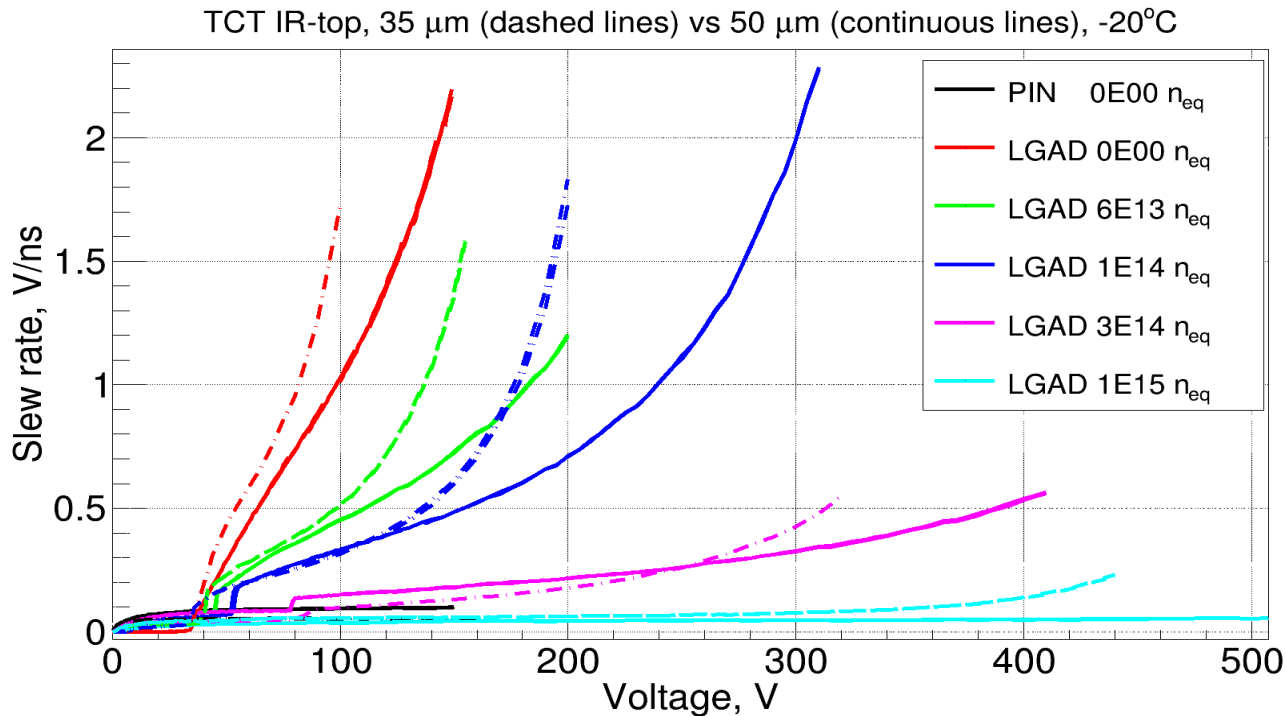
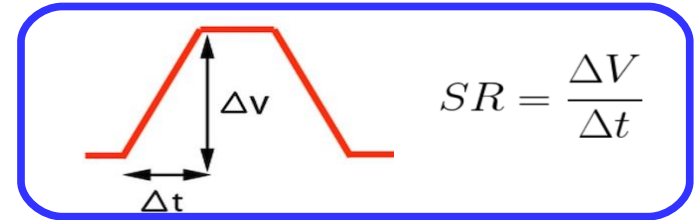


$$C \approx \left\{ \frac{e\epsilon_s N_d^{\text{eff}}}{2(V_{bi} + V_R)} \right\}^{1/2}$$



First estimation of timing performance: slew rate.

$$\delta_{time} \propto \frac{\delta_{noise}}{\left| \frac{dV}{dt} \right|} \propto \frac{\Delta t}{\Delta V} * \delta_{noise} = \frac{\delta_{noise}}{SR}$$



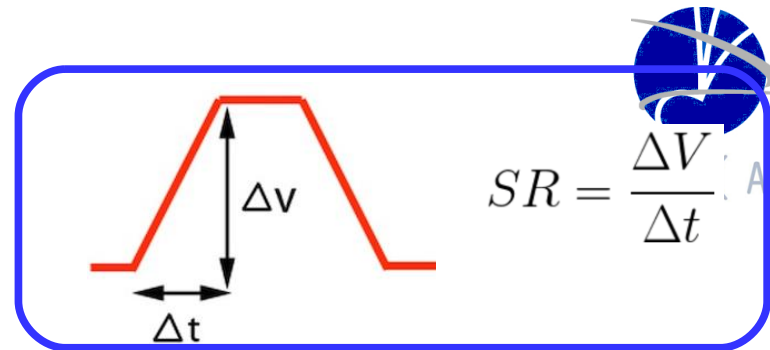
- Slew rate significantly better for the case of thinner LGADs.

- On the radiation damage mechanism
 - _ CV characteristics and IR-TCT voltage on-set point to radiation-induced Bulk's Space Charge Inversion (BSCI) (first time in a thin LGAD)
 - _ BSCI shifts the gain on-set voltage towards higher values.
- On radiation-tolerance:
 - _ Better behavior of 35mm thick LGAD compared with 50 mm thick LGAD (**gain** and **leading slew-rate** wise)
 - _ Timing resolution assessment still in progress.

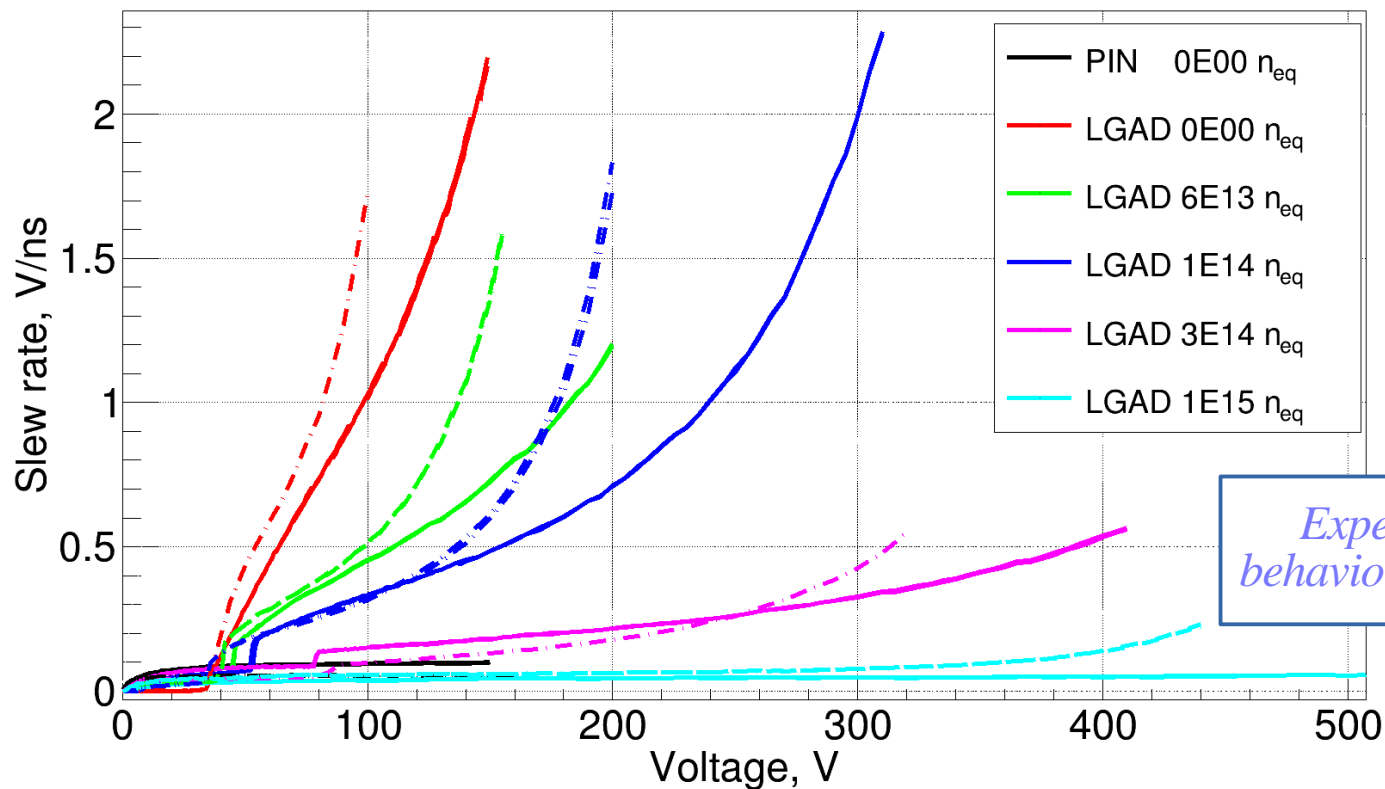
Laser measurements: Slew rate (SR)

IR laser measurements 35 μm vs 50 μm

$$\delta_{time} \propto \frac{\delta_{noise}}{\left| \frac{dV}{dt} \right|} \propto \frac{\Delta t}{\Delta V} * \delta_{noise} = \frac{\delta_{noise}}{SR}$$



TCT IR-top, 35 μm (dashed lines) vs 50 μm (continuous lines), -20°C



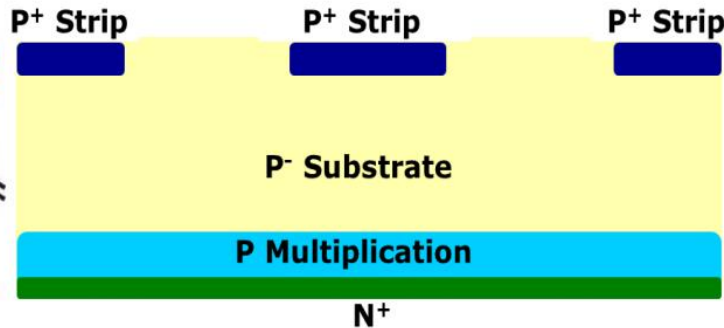
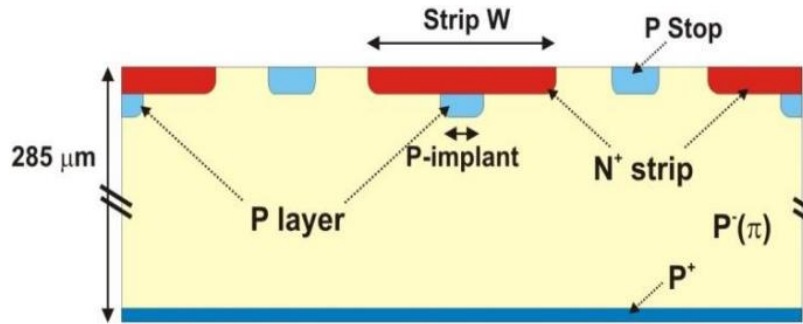
I-LGAD description

*Multiplication layer divided into strip
Collects negative carriers (e)*

Simple single side process

*Multiplication layer extended over the electrode
Collects positive carriers (h)*

Complex double side process

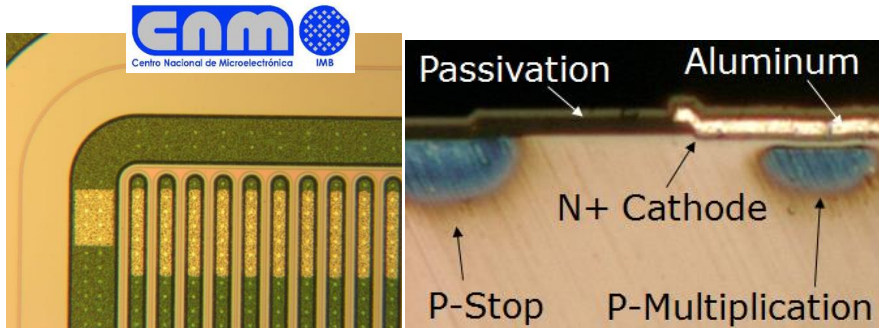


LGAD

N on P microStrip

P on P microStrip

iLGAD



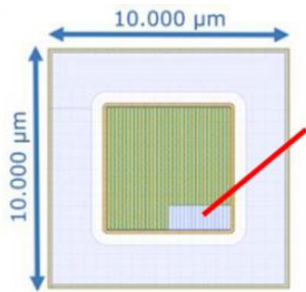
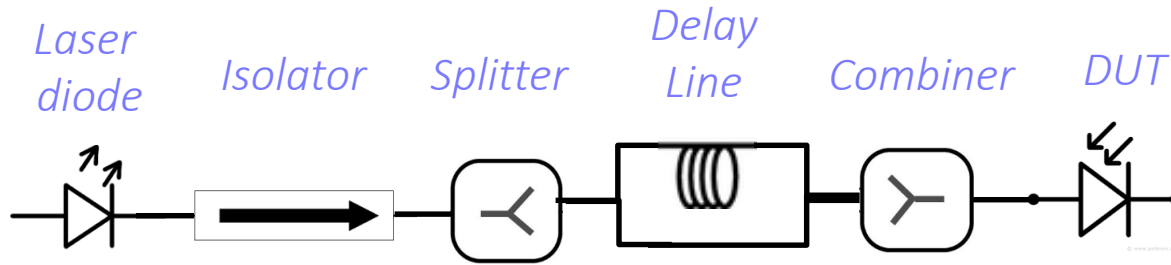
**The fill factor issue: gain spatial uniformity*

- *LGAD: multiplication layer inter-space presents reduced/suppressed gain.*
- *I-LGAD: non-segmented multiplication layer should present uniform gain.*

- ** Fill factor studies were presented at Trento workshop 2017 → [Link to the talk](#)*

https://indico.cern.ch/event/666427/contributions/2881813/attachments/1603622/2544525/20180219_I-LGAD_IvanVila.pdf

Set-up and Samples

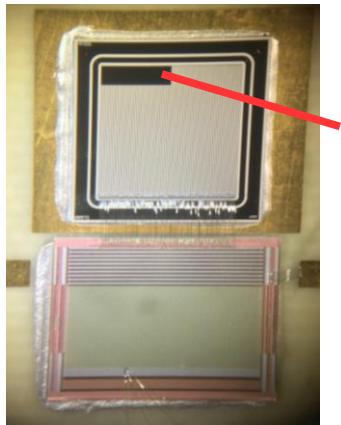


I-LGAD strip

45 strips

Thickness 285 μm

Pitch 160 μm

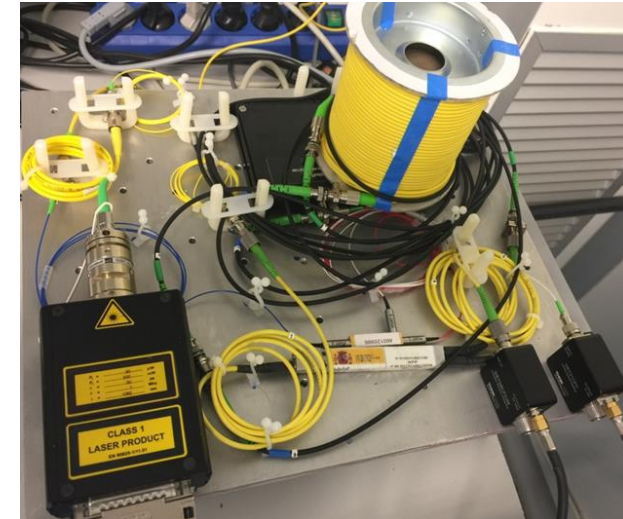


PIN strip

90 strips

Thickness 285 μm

Pitch 80 μm



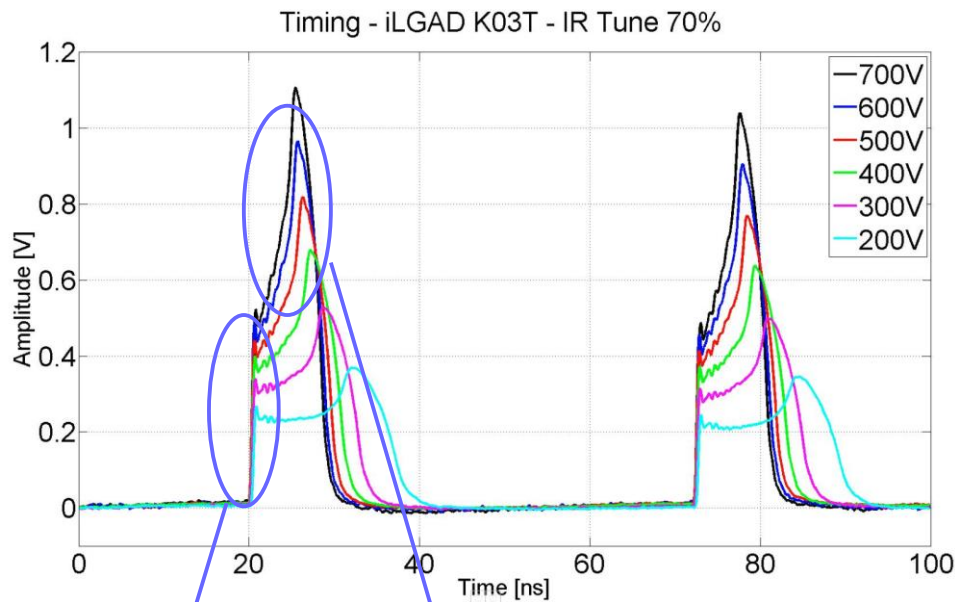
- ◆ *Time standard: constant time interval between two picosecond IR laser pulses (1060 nm)*
- ◆ *Fixed time interval between laser pulses generated by optical splitting and delayed recombination of a single laser pulse.*
- ◆ *External time reference is not needed.*

** Strips → small electrode capacitance → good for timing studies*

Set-up for timing characterization and DUT (2)

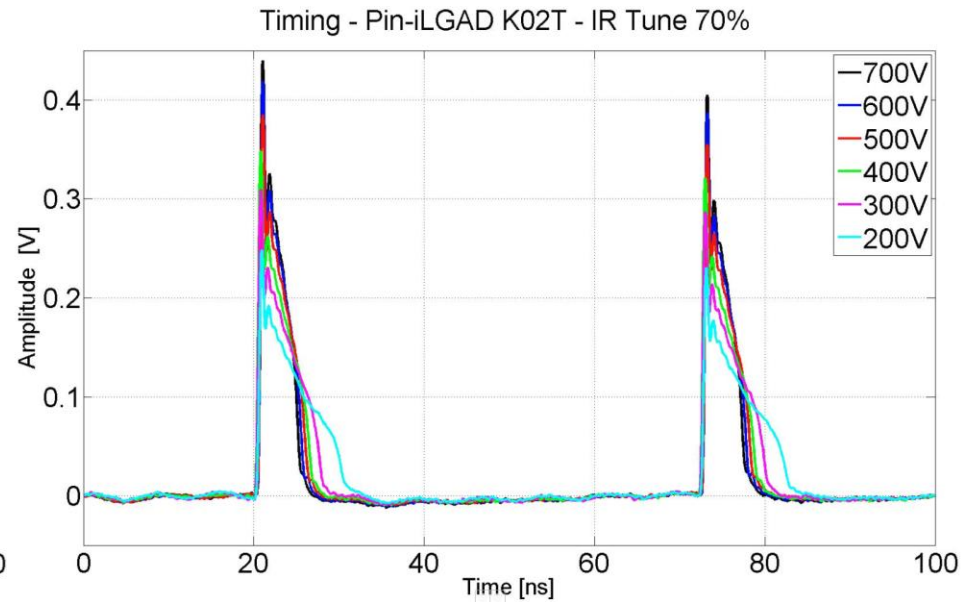


- Signal amplified (60db, miteq 1660) & digitized (25GSa/s)
- Acquired averaged waveform from I-LGAD and PIN sensors with a time interval of 52.23 ns between pulses



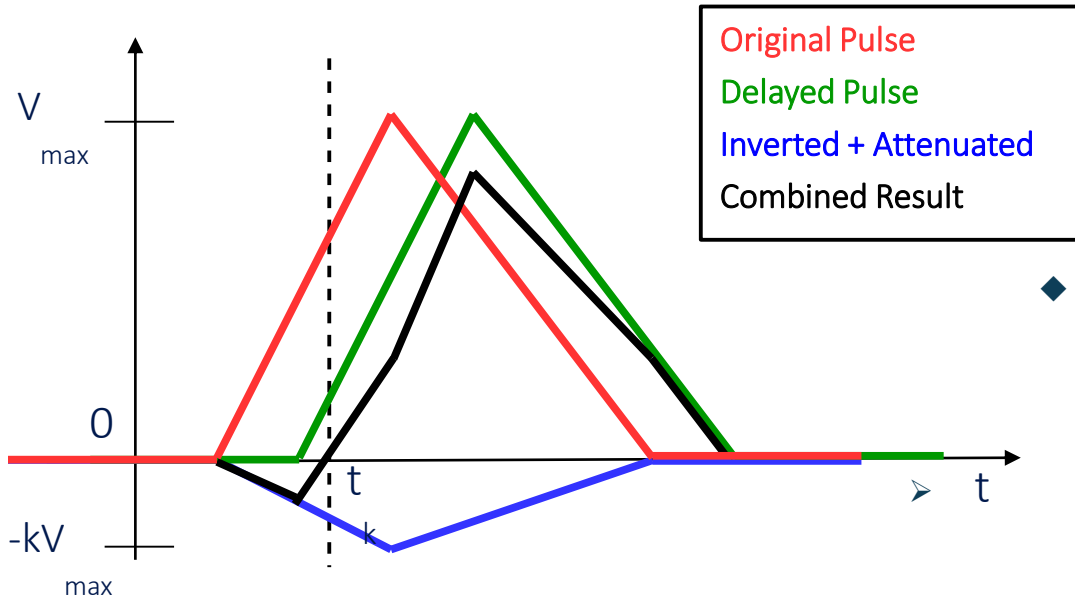
Primary electrons contribution

Secondary holes contribution



Timing computation: Constant Fraction Discrimination method (CFD)

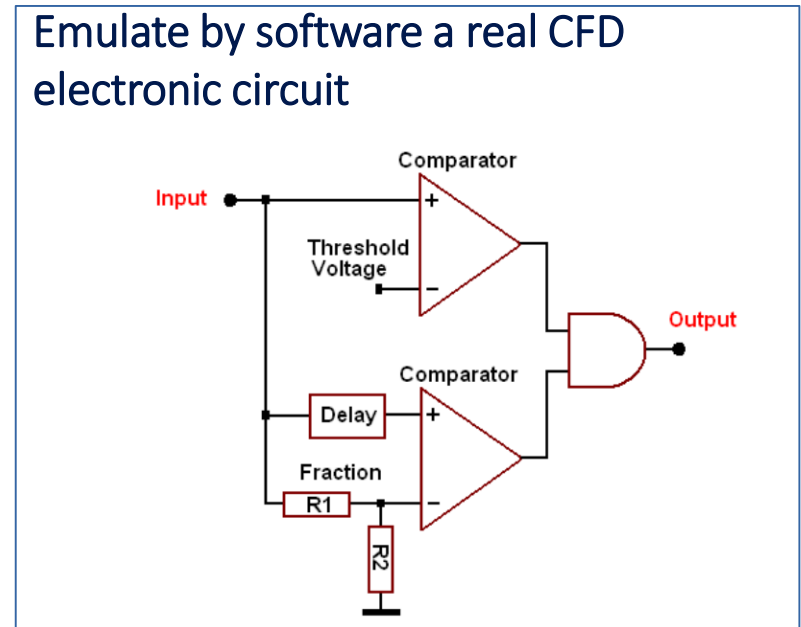
◆ CFD principles of operation



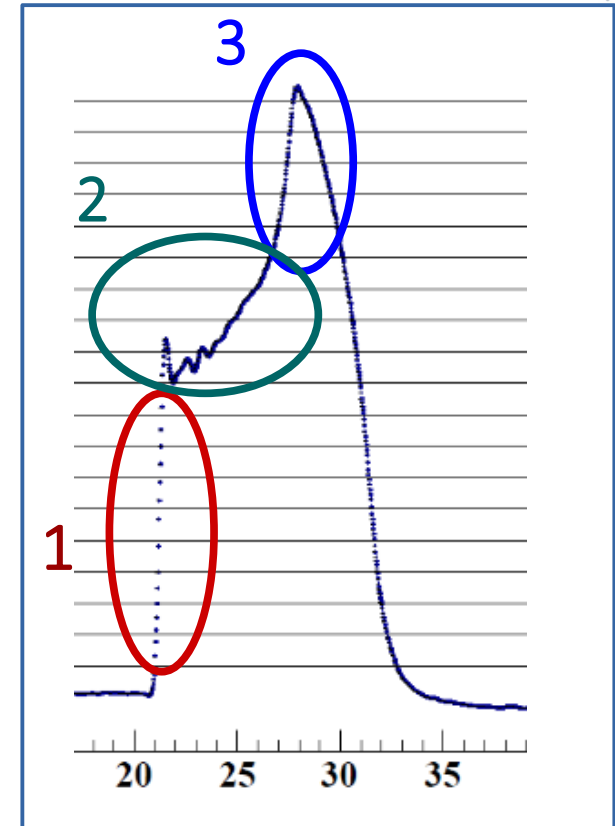
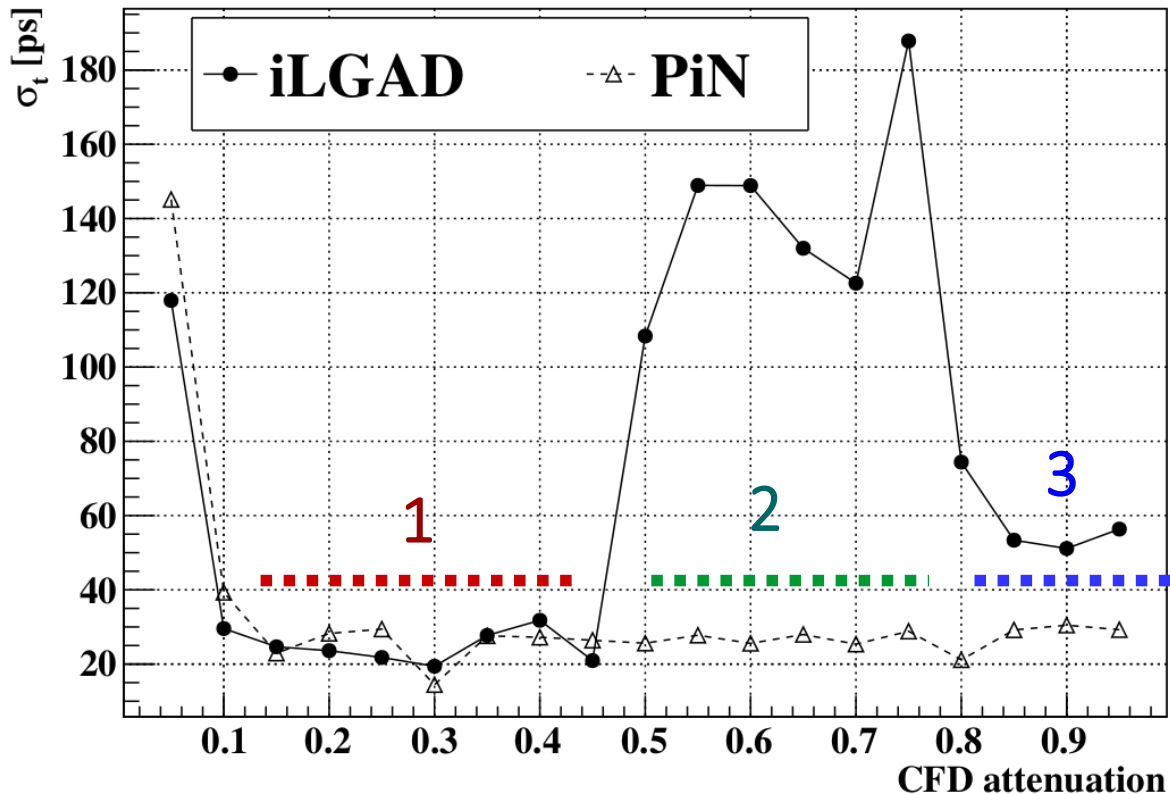
◆ Emulate by software a real CFD electronic circuit

- Split the input signal in two parts
- Delay on part
- Attenuate ($-kV$) and invert the other
- Add the two signals together
- The zero crossing point of the bipolar signal (t_{max}) will always be constant

k



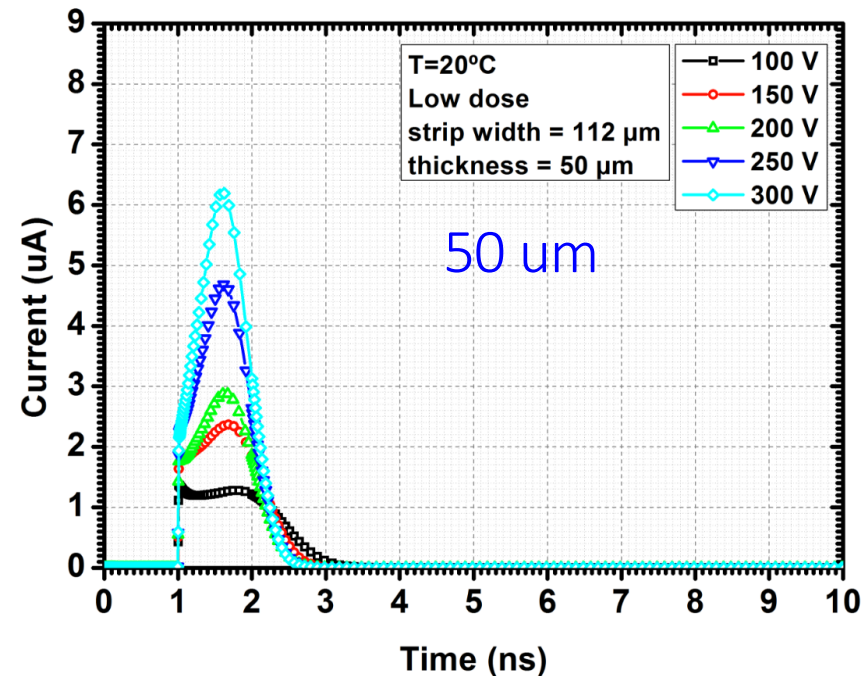
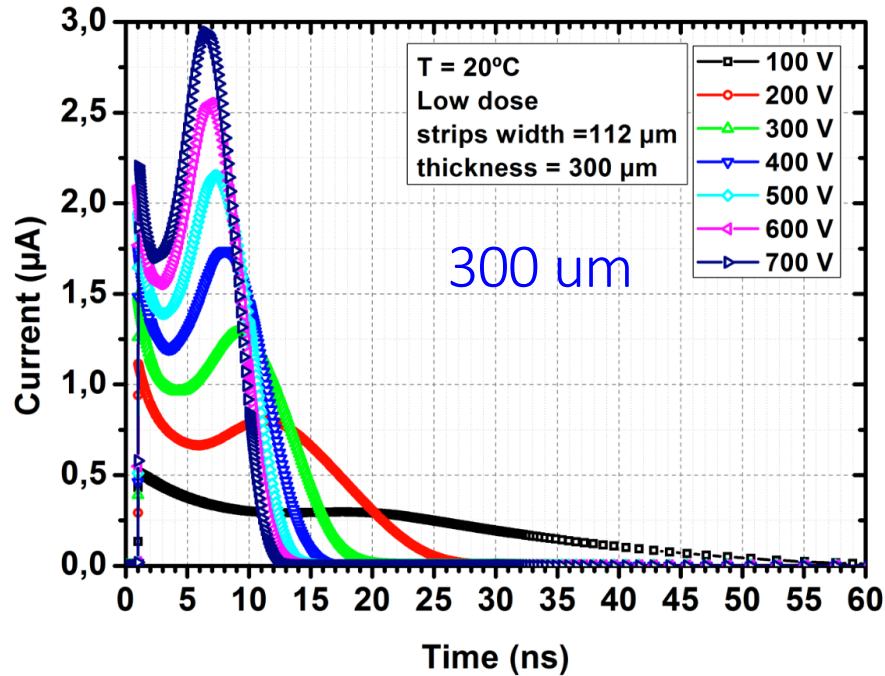
Constant Fraction Discrimination method (CFD):



- Optimum value of the k parameter for the I-LGAD in zone 1.
- For the PIN k parameter is optimum in almost the full range.

Constant Fraction Discrimination method (CFD):

Simulation 300 μm vs 50 μm .



- First part of the signal very fast and good for timing but not as good in SNR terms.
- Second part still good with better SNR but worse rise time.
- If we go to 50 μm we can have both benefits: Good SNR and low rise time.

- We compared the timing performance of one I-LGAD strip sensor with a similar PIN strip sensor.
- Time resolution was estimated using a more realistic CFD method.
- Better time resolution with the I-LGAD sensor for a lower SNR.
- Simulations show a promising time performance of 50 μm I-LGADs strip devices.

THANK YOU FOR
YOUR ATTENTION

Parameter extraction of the waveform.

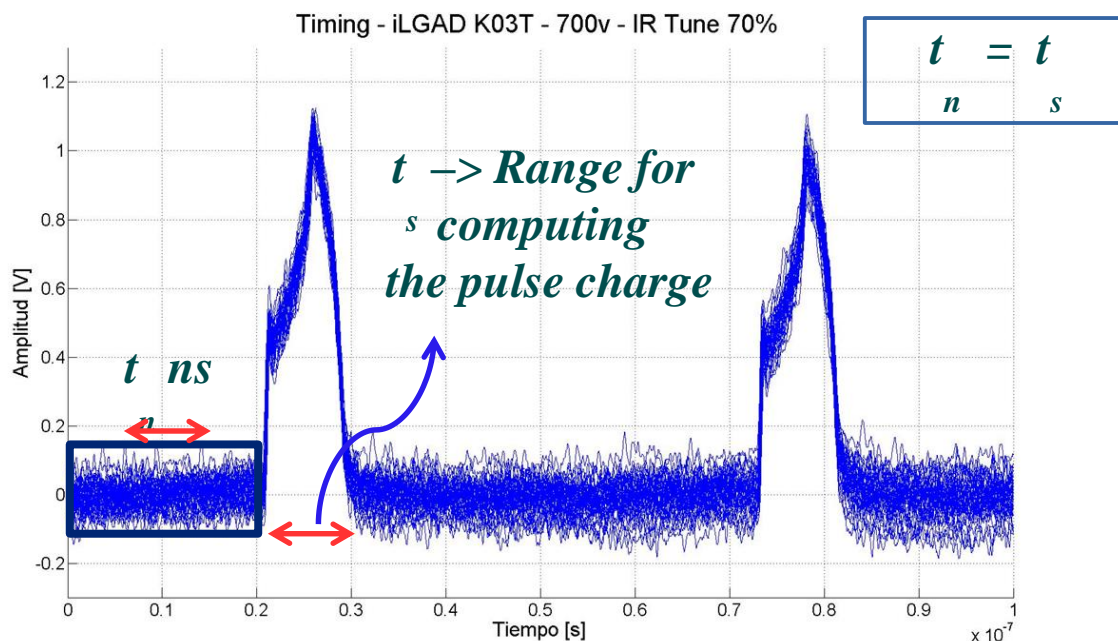


- ◆ *Single-shot (non-averaged) superposition of signals.*
- ◆ *For each shot measured: Rise time, Signal amplitude and noise.*
- ◆ *Signal estimation as the charge under the transient waveform.*
- ◆ *Noise estimation as the RMS of charge (from the first nanoseconds of the waveform).*

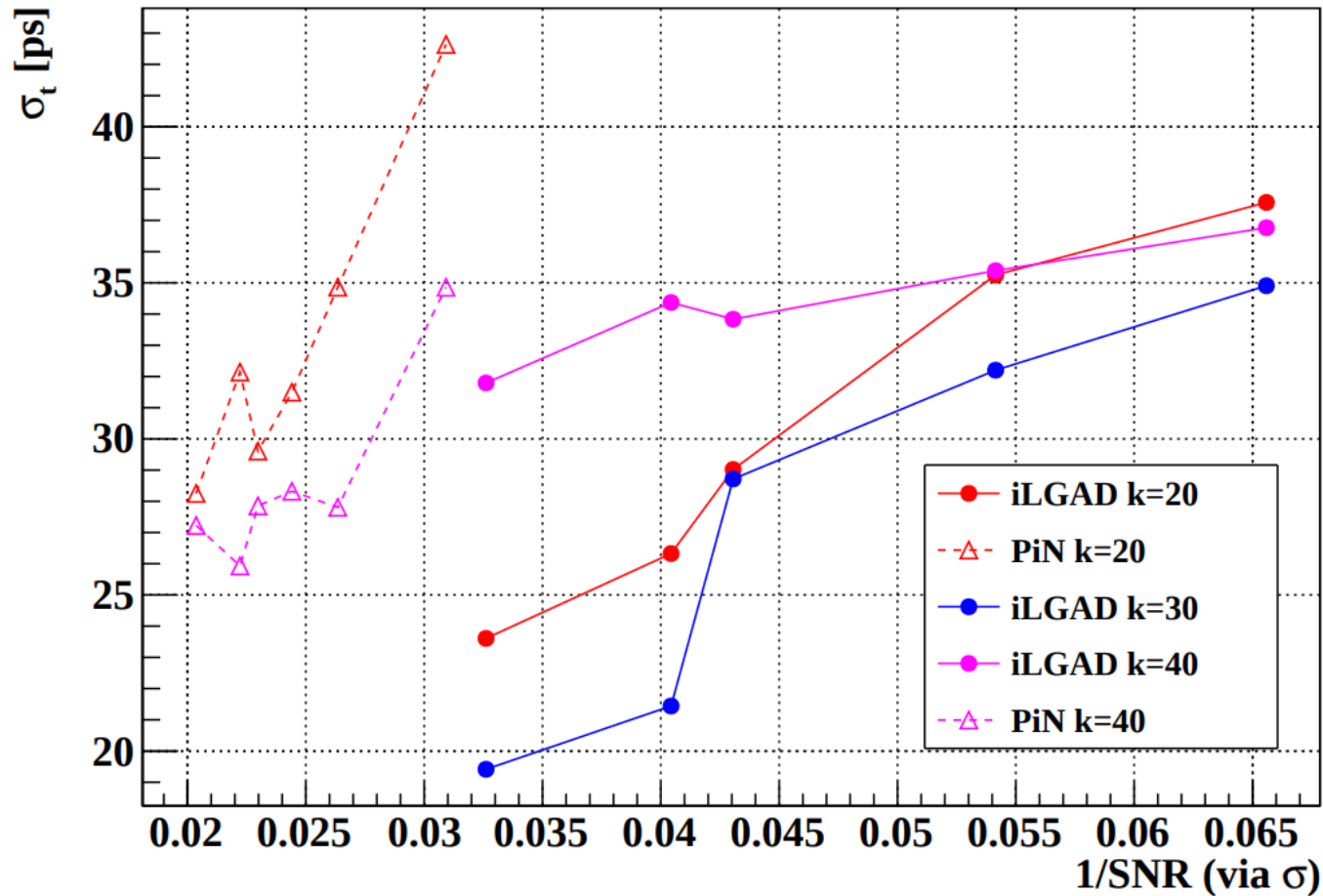
$\sigma \equiv \text{RMS (Charge baseline)}$

$$\text{SNR} \equiv \frac{\text{Signal Charge}}{\sigma}$$

Waveform section from where the baseline noise is estimated



Constant Fraction Discrimination method (CFD):



➤ Better time resolution for the I-LGAD even with lower SNR.

... a particular case concerning radiation tolerance.

- The layout of the proposed LHC timing detectors: a mosaic of mini-pads (elements with area of few mm^2)
- A pad-like LGAD is also a pad-like I-LGAD therefore they exhibit the same radiation tolerance

